What is claimed is:

1. An process for the electrodeposition of a nickel or nickel-alloy coating on a substrate, the process comprising:

immersing the metal substrate in a bath comprising nickel ions and an additive having the general formula:

Ĺ

$$H_2C=CHCH_2NR_1R_2$$
 or $[H_2C=CHCH_2N^{\dagger}R_1R_2R_3]_nX^n$

wherein R_1 , R_2 and R_3 are selected from the functional groups consisting or hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X^n is an n-valent inorganic or organic anion.

- 2. The process according to claim 1 wherein Xⁿ⁻ is an n-valent anion selected from the group of chloride, bromide, fluoride, sulfate, acetate, and tetrafluoroborate.
- 3. The process according to claim 1 wherein the bath further comprises alloying metal alloys.
- 4. An aqueous acidic plating bath for the electrodeposition of a nickel or nickel alloy deposit on a substrate comprising:
 - a) nickel ions; and
 - b) an additive having the general formula:

$$H_2C=CHCH_2NR_1R_2$$
 or $[H_2C=CHCH_2N^{\dagger}R_1R_2R_3]_nX^{n-1}$

wherein R_1 , R_2 and R_3 are selected from the functional groups consisting or hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X^{n-} is an n-valent inorganic or organic anion.

- 5. An aqueous acidic plating bath for the electrodeposition of a nickel or nickel alloy deposit on a substrate comprising:
 - a) nickel ions;
 - b) at least one Class I brightener; and
 - c) an additive having the general formula:

$$H_2C=CHCH_2NR_1R_2$$
 or $[H_2C=CHCH_2N^+R_1R_2R_3]_nX^n$

wherein R_1 , R_2 and R_3 are selected from the functional groups consisting or hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X^{n-} is an n-valent inorganic or organic anion.

- 6. An aqueous acidic plating bath for the electrodeposition of a nickel or nickel alloy deposit on a substrate comprising:
 - a) nickel ions;
 - b) at least one Class II brightener; and
 - c) an additive having the general formula:

$$H_2C=CHCH_2NR_1R_2$$
 or $[H_2C=CHCH_2N^{\dagger}R_1R_2R_3]_nX^{n-1}$

wherein R_1 , R_2 and R_3 are selected from the functional groups consisting or hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X^{n-} is an n-valent inorganic or organic anion.

- 7. An aqueous acidic plating bath for the electrodeposition of a nickel or nickel alloy deposit on a substrate comprising:
 - a) nickel ions;
 - b) at least one Class I brightener;
 - c) at least one Class II brightener; and
 - d) an additive having the general formula:

$$H_2C=CHCH_2NR_1R_2$$
 or $[H_2C=CHCH_2N^{\dagger}R_1R_2R_3]_nX^{n-1}$

wherein R_1 , R_2 and R_3 are selected from the functional groups consisting or hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X^{n-} is an n-valent inorganic or organic anion.

- 8. An aqueous acidic plating bath for the electrodeposition of a nickel or nickel alloy deposit on a substrate comprising:
 - a) nickel ions;
 - b) alloying metal ions;
 - c) at least one Class I brightener;
 - d) at least one Class II brightener; and
 - e) an additive having the general formula:

$$H_2C=CHCH_2NR_1R_2$$
 or $[H_2C=CHCH_2N^+R_1R_2R_3]_nX^n$

wherein R_1 , R_2 and R_3 are selected from the functional groups consisting or hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X^{n-} is an n-valent inorganic or organic anion.

- 9. The bath according to claim 8 wherein the alloying metal ions are selected from the group of iron, cobalt, tin, and zinc.
- 10. The bath according to claim 4 wherein Xⁿ⁻ is an n-valent anion selected from the group of chloride, bromide, fluoride, sulfate, acetate, and tetrafluoroborate.